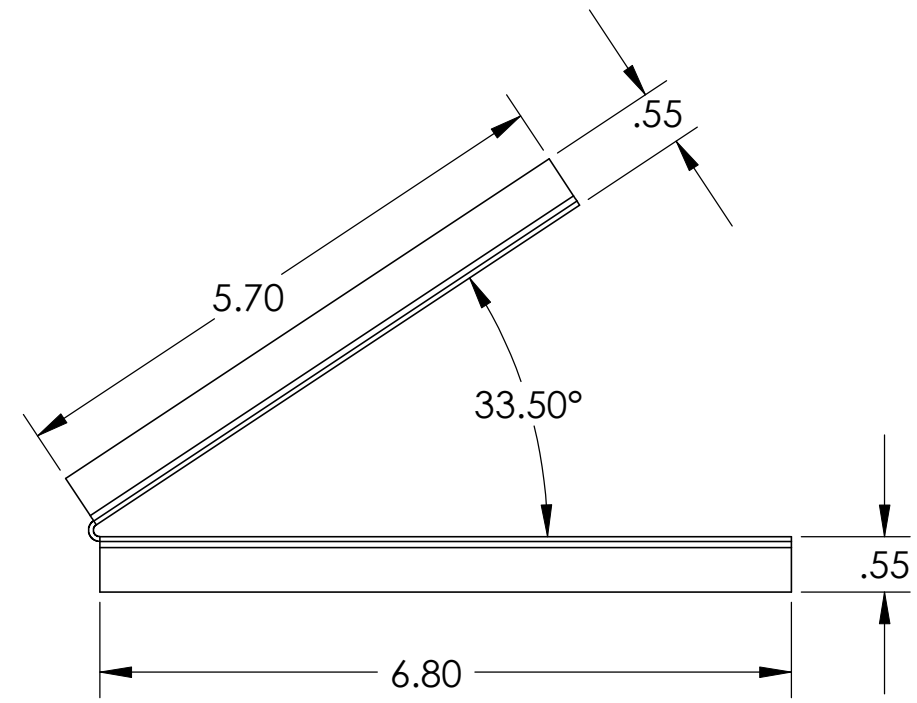
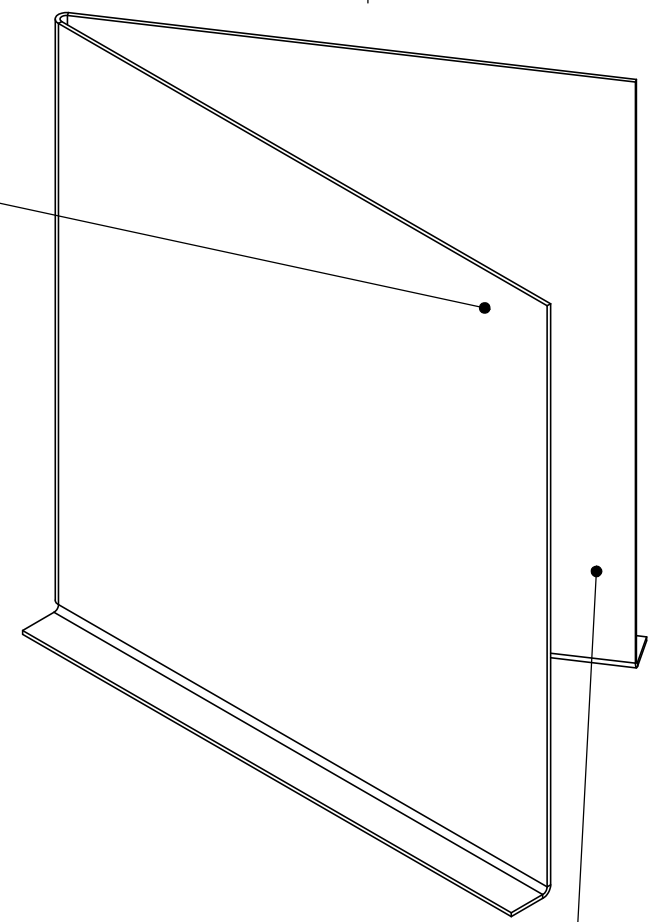


8 7 6 5 4 3 2 1

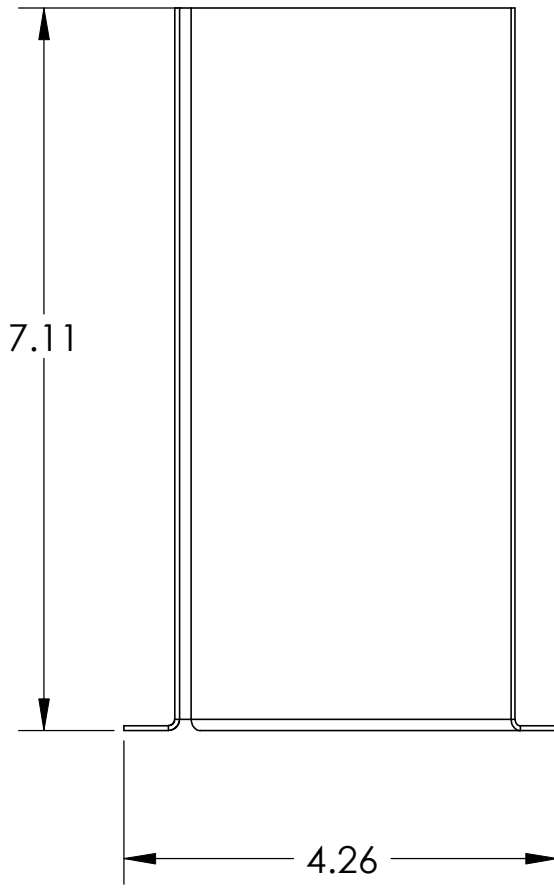
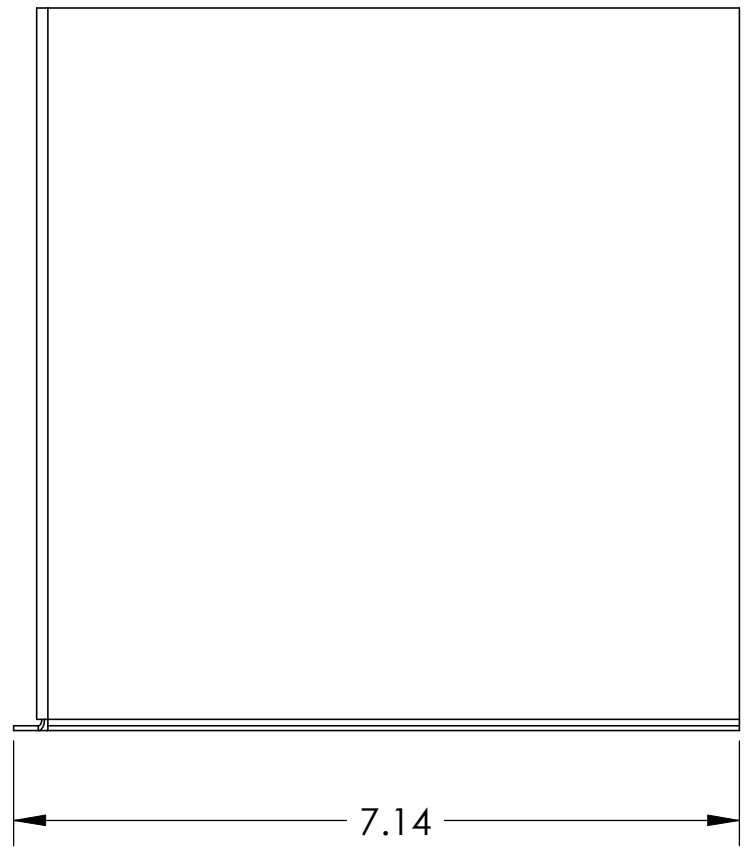
REV.	DATE	DCN #	DRAWING TREE #



ENGRAVE PART AND SERIAL NUMBER WITH FORMAT:
D080338-A-S/N00x



MIRROR FINISH SIDE

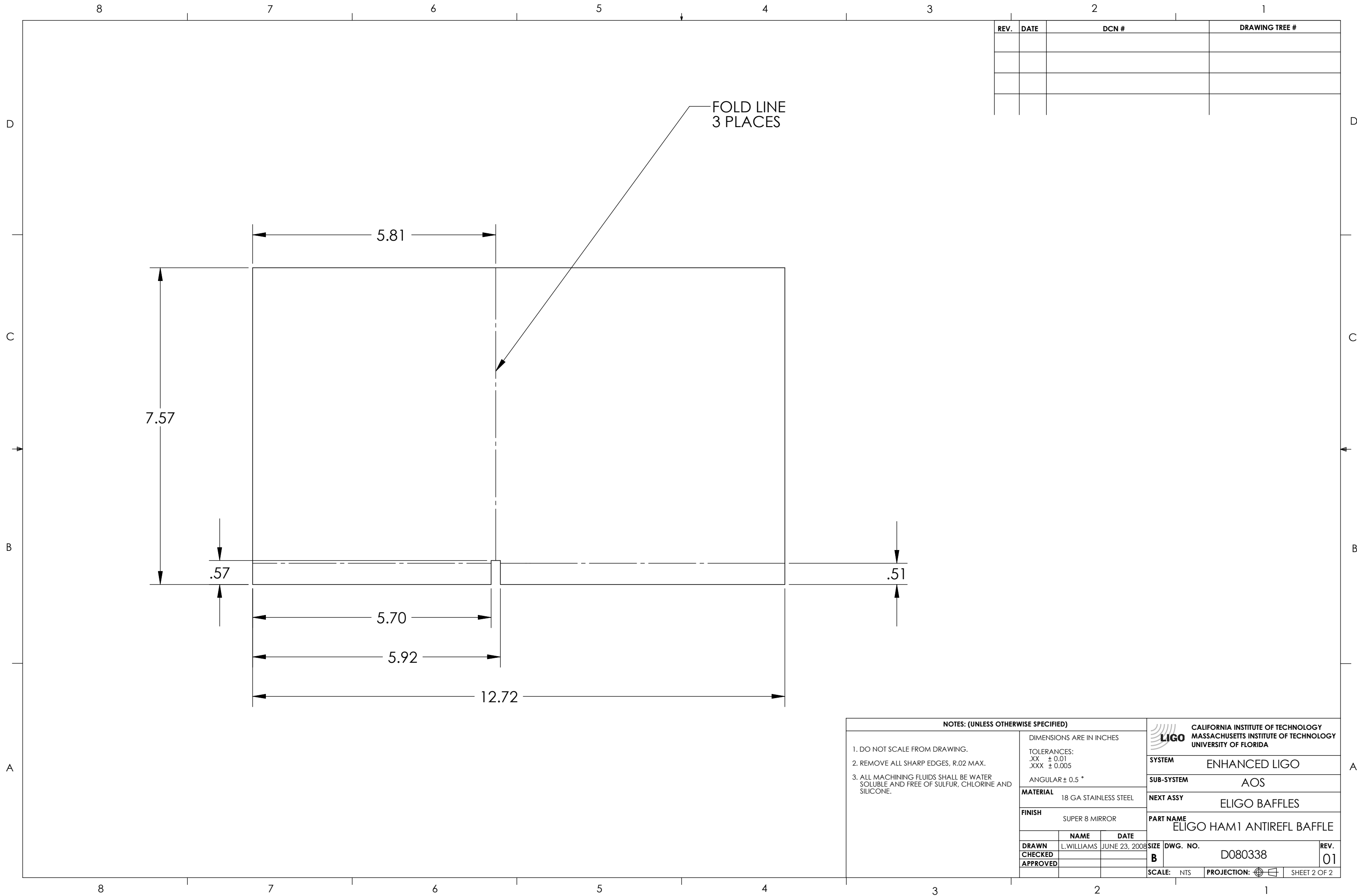


NOTES: (UNLESS OTHERWISE SPECIFIED)				CALIFORNIA INSTITUTE OF TECHNOLOGY MASSACHUSETTS INSTITUTE OF TECHNOLOGY UNIVERSITY OF FLORIDA												
1. DO NOT SCALE FROM DRAWING. 2. REMOVE ALL SHARP EDGES, R.02 MAX. 3. ALL MACHINING FLUIDS SHALL BE WATER SOLUBLE AND FREE OF SULFUR, CHLORINE AND SILICONE. 4. ALL BENDS ARE R=1/16" ON THE INSIDE OF THE BEND. 5. SEE SECOND SHEET FOR FLAT LAYOUT.	DIMENSIONS ARE IN INCHES															
	TOLERANCES: .XX ± 0.01 .XXX ± 0.005															
	ANGULAR ± 0.5 °		SYSTEM	ENHANCED LIGO												
	MATERIAL 18 GA STAINLESS STEEL		SUB-SYSTEM	AOS												
	FINISH SUPER 8 MIRROR		NEXT ASSY	ELIGO BAFFLES												
<table border="1"> <thead> <tr> <th> </th> <th>NAME</th> <th>DATE</th> </tr> </thead> <tbody> <tr> <td>DRAWN</td> <td>L.WILLIAMS</td> <td>JUNE 23, 2008</td> </tr> <tr> <td>CHECKED</td> <td> </td> <td> </td> </tr> <tr> <td>APPROVED</td> <td> </td> <td> </td> </tr> </tbody> </table>			NAME	DATE	DRAWN	L.WILLIAMS	JUNE 23, 2008	CHECKED			APPROVED			PART NAME	ELIGO HAM1 ANTIREFL BAFFLE	
	NAME	DATE														
DRAWN	L.WILLIAMS	JUNE 23, 2008														
CHECKED																
APPROVED																
QTY 2		SCALE: NTS	PROJECTION:	SHEET 1 OF 2	<table border="1"> <tr> <td>SIZE</td> <td>DWG. NO.</td> <td>REV.</td> </tr> <tr> <td>B</td> <td>D080338</td> <td>01</td> </tr> </table>	SIZE	DWG. NO.	REV.	B	D080338	01					
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B	D080338	01														

D
C
B
A

D
C
B
A

8 7 6 5 4 3 2 1



REV.	DATE	DCN #	DRAWING TREE #

NOTES: (UNLESS OTHERWISE SPECIFIED)

- DO NOT SCALE FROM DRAWING.
- REMOVE ALL SHARP EDGES, R.02 MAX.
- ALL MACHINING FLUIDS SHALL BE WATER SOLUBLE AND FREE OF SULFUR, CHLORINE AND SILICONE.

DIMENSIONS ARE IN INCHES
TOLERANCES:
.XX ± 0.01
.XXX ± 0.005
ANGULAR ± 0.5 °

MATERIAL 18 GA STAINLESS STEEL
FINISH SUPER 8 MIRROR

	NAME	DATE
DRAWN	L.WILLIAMS	JUNE 23, 2008
CHECKED		
APPROVED		

SCALE: NTS **PROJECTION:** **SHEET 2 OF 2**

CALIFORNIA INSTITUTE OF TECHNOLOGY MASSACHUSETTS INSTITUTE OF TECHNOLOGY UNIVERSITY OF FLORIDA	
SYSTEM	ENHANCED LIGO
SUB-SYSTEM	AOS
NEXT ASSY	ELIGO BAFFLES
PART NAME	ELIGO HAM1 ANTIREFL BAFFLE
SIZE	DWG. NO. D080338
REV.	01